

Application Data Sheet

Application Information

Application Type::	Regular
Subject Matter::	Utility
Suggested Group Art Unit::	N/A
CD-ROM or CD-R?::	None
Sequence submission?::	None
Computer Readable Form (CRF)?::	No
Title::	METHOD FOR PRODUCING A DEEP TRENCH CAPACITOR IN A SEMICONDUCTOR SUBSTRATE
Attorney Docket Number::	543822005300
Request for Early Publication?::	No
Request for Non-Publication?::	No
Total Drawing Sheets::	Thirteen (13)
Small Entity?::	No
Petition included?::	No
Secrecy Order in Parent Appl.?::	No

Applicant Information

Applicant Authority Type::	Inventor
Primary Citizenship Country::	Taiwan
Status::	Full Capacity
Given Name::	Steve
Family Name::	WANG
City of Residence::	Dresden
Country of Residence::	Germany
Street of mailing address::	Sagarder Weg 2
City of mailing address::	Dresen
Country of mailing address::	Germany
Postal or Zip Code of mailing address::	D-01109

Applicant Authority Type:: Inventor
Primary Citizenship Country:: Taiwan
Status:: Full Capacity
Given Name:: Kae-Horng
Family Name:: WANG
City of Residence:: Dresden
Country of Residence:: Germany
Street of mailing address:: Tieckstrasse 10
City of mailing address:: Dresden
Country of mailing address:: Germany
Postal or Zip Code of mailing address:: D01099

Foreign Priority Information

Country::	Application number::	Filing Date::	Priority Claimed::

Correspondence Information

Correspondence Customer Number:: 25227

Representative Information

Representative Customer Number:: 25227

Assignee Information

Assignee name:: Infineon Technologies AG
Street of mailing address:: St.-Martin-Str. 53
City of mailing address:: München
Country of mailing address:: Germany
Postal or Zip Code of mailing address:: 81669